

EAST Search History

EAST Search History (Prior Art)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	4	((MAKIKO) near2 (KITAZOE)).INV.	US-PGPUB; USPAT	ADJ	ON	2010/08/17 09:05
L2	1	((HIROMI) near2 (ITHO)).INV.	US-PGPUB; USPAT	ADJ	ON	2010/08/17 09:05
L3	5	((SHIN) near2 (ASARI)).INV.	US-PGPUB; USPAT	ADJ	ON	2010/08/17 09:05
L4	35	((KAZUYA) near2 (SAITO)).INV.	US-PGPUB; USPAT	ADJ	ON	2010/08/17 09:05
L5	40	L1 or L2 or L3 or L4	US-PGPUB; USPAT	ADJ	ON	2010/08/17 09:05
L6	40	L5	US-PGPUB; USPAT; EPO	ADJ	ON	2010/08/17 09:05
L7	1	"6689220".pn.	US-PGPUB; USPAT; EPO	ADJ	ON	2010/08/17 09:11
L8	1004	rectang\$6 with pulse same (flow or MFC)	US-PGPUB; USPAT; EPO	ADJ	ON	2010/08/17 10:02
L9	11	rectang\$6 with pulse with (gas flow or MFC)	US-PGPUB; USPAT; EPO	ADJ	ON	2010/08/17 10:02
L10	8588	(siN or silicon nitride or "si.sub.3n.sub.4") and ((rectang\$7 with (puls\$4 or flow)) or simultaneous\$4 with (valve or switch\$4))	US-PGPUB; USPAT; EPO; DERWENT	ADJ	ON	2010/08/17 10:04
L11	1964	l10 and ("h.sub.2" or hydrogen)	US-PGPUB; USPAT; EPO; DERWENT	ADJ	ON	2010/08/17 10:06
L12	623	l10 and ("h.sub.2" or hydrogen) with (treat\$6 or post-treat\$6 or posttreat\$6 or SiN or silicon nitride or "si.sub.3.n.sub.4")	US-PGPUB; USPAT; EPO; DERWENT	ADJ	ON	2010/08/17 10:07

L13	97	I10 and ("h.sub.2" or hydrogen) with (treat\$6 or post-treat\$6 or posttreat\$6 or SiN or silicon nitride or "si.sub.3.n.sub.4") same (dens\$6 or multi-layer or mulitple layer)	US-PGPUB; USPAT; EPO; DERWENT	ADJ	ON	2010/08/17 10:07
L14	92	I13 and ("427"/\$. ccls. or CVD or vapor deposition)	US-PGPUB; USPAT; EPO; DERWENT	ADJ	ON	2010/08/17 10:08
L15	10	I10 and ("h.sub.2" or hydrogen) with (treat\$6 or post-treat\$6 or posttreat\$6) same (SiN or silicon nitride or "si.sub.3.n.sub.4") same (dens\$6 or multi-layer or mulitple layer)	US-PGPUB; USPAT; EPO; DERWENT	ADJ	ON	2010/08/17 10:09
L16	141	I10 and ("h.sub.2" or hydrogen) with (treat\$6 or post-treat\$6 or posttreat\$6) same (SiN or silicon nitride or "si.sub.3.n.sub.4")	US-PGPUB; USPAT; EPO; DERWENT	ADJ	ON	2010/08/17 10:10
L17	164	I10 and ("h.sub.2" or hydrogen) with (treat\$6 or post-treat\$6 or posttreat\$6 or dens\$6) same (SiN or silicon nitride or "si.sub.3.n.sub.4")	US-PGPUB; USPAT; EPO; DERWENT	ADJ	ON	2010/08/17 10:10

EAST Search History (I nterference)

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